

# United States Patent and Trademark Office

UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER OF PATENTS AND TRADEMARKS Washington, D.C. 20231 www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/884,451	06/19/2001	Robert Dolan	101361-0043	1957
7:	590 12/13/2002			
NUTTER, MCCLENNEN & FISH, LLP Reza Mollaaghababa One International Place			EXAMINER	
			MALDONADO, JULIO J	
Boston, MA 02110-2699			ART UNIT	PAPER NUMBER
			2823	
			DATE MAILED: 12/12/2002	

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)				
Office Action Summany	09/884,451	DOLAN ET AL.				
Office Action Summary	Examiner	Art Unit				
TI MAN INO DATE of this communication con	Julio J. Maldonado	2823				
The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply						
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION.  - Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.  - If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely.  - If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.  - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133).  - Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).  Status						
1) Responsive to communication(s) filed on 11 C						
,	is action is non-final.					
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.						
Disposition of Claims						
4) Claim(s) 1-19 is/are pending in the application.						
4a) Of the above claim(s) <u>14-19</u> is/are withdrawn from consideration.						
5) Claim(s) is/are allowed.						
6)⊠ Claim(s) <u>1-14</u> is/are rejected.						
7) Claim(s) is/are objected to.	7) Claim(s) is/are objected to.					
8) Claim(s) are subject to restriction and/or election requirement.						
Application Papers						
9) The specification is objected to by the Examiner.  10) The drawing(s) filed on is/are: a) accepted or b) objected to by the Examiner.						
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).						
11) The proposed drawing correction filed on is: a) approved b) disapproved by the Examiner.						
If approved, corrected drawings are required in reply to this Office action.						
12) The oath or declaration is objected to by the Examiner.						
Priority under 35 U.S.C. §§ 119 and 120						
13) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).						
a) All b) Some * c) None of:						
1. Certified copies of the priority documents have been received.						
2. Certified copies of the priority documents have been received in Application No						
<ul> <li>3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).</li> <li>* See the attached detailed Office action for a list of the certified copies not received.</li> </ul>						
14) Acknowledgment is made of a claim for domestic priority under 35 U.S.C. § 119(e) (to a provisional application).						
a) The translation of the foreign language provisional application has been received.  15) Acknowledgment is made of a claim for domestic priority under 35 U.S.C. §§ 120 and/or 121.						
Attachment(s)						
1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449) Paper No(s) 6	5) Notice of Informa	ary (PTO-413) Paper No(s) Il Patent Application (PTO-152)				

Application/Control Number: 09/884,451 Page 2

Art Unit: 2823

### **DETAILED ACTION**

1. The non-final rejection as set forth in paper No.5 is withdrawn in response to applicants' amendments.

- 2. A new 103(a) rejection is made as set forth in this Office Action.
- 3. Claims 14-19 are newly added. Thus, claims 1-19 are pending in this application.

### Election/Restrictions

4. Newly submitted claims 14-19 are directed to an invention that is independent or distinct from the invention originally claimed for the following reasons: claims 14-19 are directed to an apparatus for producing SIMOX wafer, classified in class 250, subclass 492.

Since applicant has received an action on the merits for the originally presented invention, this invention has been constructively elected by original presentation for prosecution on the merits. Accordingly, claims 14-19 are withdrawn from consideration as being directed to a non-elected invention. See 37 CFR 1.142(b) and MPEP § 821.03.

### Claim Rejections - 35 USC § 112

- 5. The following is a quotation of the second paragraph of 35 U.S.C. 112:
  The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.
- 6. Claim 2 is rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention. Applicants' cite "...selecting the fluid from the group

Application/Control Number: 09/884,451

Art Unit: 2823

consisting of water vapor, heavy water, air, argon, and hydrogen gases...". Specifically, air is combination of essentially molecular nitrogen and molecular oxygen. However, independent claim 1 recited introducing a fluid other than oxygen. Appropriate correction is required.

## Claim Rejections - 35 USC § 103

- 7. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
  - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 8. Claims 1-13 are rejected under 35 U.S.C. 103(a) as being unpatentable over Sakaguchi et al. (U.S. 6,313,014) in view of Hsu (U.S. 5,468,657).

In reference to claims 1-5 and 12-13, Sakaguchi et al. (Fig. 1-5) in a related method to form buried oxide films teach placing the substrate (23) into a vacuum chamber, the substrate being treated with a fluid other than molecular oxygen, said fluid comprising hydrogen and said hydrogen is a surface inhibiting agent; evacuating the vacuum chamber to a first pressure; and implanting ions into the substrate (23) to form a buried oxide layer under a top silicon layer (22), where the fluid inhibits formations of threading dislocations in the top silicon layer (22) for reducing a defect density of the processed substrate; and selecting the fluid from fluids that inhibit formations of threading dislocations in the top silicon layer (22) for reducing a defect density of the processed substrate (23) (column 2, line 53 – column 16, line 25).

Application/Control Number: 09/884,451

Art Unit: 2823

Sakaguchi et al. fail to teach implanting oxygen atoms while the fluid other than molecular oxygen is present. However, Hsu (Figs.1C-3) in a related method to form a SIMOX structure, teach the steps of placing a substrate in a chamber to a first pressure; introducing nitrogen into the chamber; and implanting ions into the substrate while the is present (column 2, line 20 – column 10, line 63). Therefore, it would have been obvious to one of ordinary skill in the art at the time of the invention was made to form the implant the silicon substrate as taught by Hsu in the buried oxide film of Sakaguchi, since this would reduce the processing steps (column 10, lines 55 – 63).

In reference to claims 6 and 7, Sakaguchi et al. in combination with Hsu substantially teach all aspects of the invention but fail to teach the first pressure is less than about 1x10<sup>-5</sup> Torr and a second pressure less than about 1x10<sup>-3</sup>. However, the selection of the claimed ranges is obvious because it is a matter of determining optimum process condition by routine experimentation with a limited number of species. In re Jones, 162 USPQ 224 (CCPA 1955)(the selection of optimum ranges within prior art general conditions is obvious) and In re Boesch, 205 USPQ 215 (CCPA 1980)(discovery of optimum value of result effective variable in a known process is obvious).

In reference to claims 8-11, Sakaguchi et al. in combination with Hsu teach controlling the amount of fluid introduced into the vacuum chamber based upon a parameter measured in the chamber, said parameter consisting from the group consisting of ion concentration and temperature; where the parameter further comprises

Application/Control Number: 09/884,451

Art Unit: 2823

a measurement of an ion beam current comprising a decrease in the beam current due to fluid in the chamber (column 2, line 53 – column 16, line 25).

### Response to Arguments

9. Applicant's arguments with respect to claims 1 and 12 have been considered but are most in view of the new ground(s) of rejection.

### Conclusion

10. Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

11. Papers related to this application may be submitted directly to Art Unit 2823 by facsimile transmission. Papers should be faxed to Art Unit 2823 via the Art Unit 2823 Fax Center located in Crystal Plaza 4, room 3C23. The faxing of such papers must conform to the notice published in the Official Gazette, 1096 OG 30 (15 November

Art Unit: 2823

1989). The Art Unit 2823 Fax Center number is (703) 305-3432. The Art Unit 2823 Fax

Center is to be used only for papers related to Art Unit 2823 applications.

Any inquiry concerning this communication or earlier communications from the

examiner should be directed to Julio J. Maldonado at (703) 306-0098 and between the

hours of 8:00 AM to 4:00 PM (Eastern Standard Time) Monday through Friday or by e-

mail via julio.maldonado@uspto.gov. If attempts to reach the examiner by telephone

are unsuccessful, the examiner's supervisor, Olik Chaudhuri, can be reached on (703)

306-2794.

Any inquiry of a general nature or relating to the status of this application should

be directed to the Group 2800 Receptionist at (703) 308-0956.

Julio J. Maldonado

Patent Examiner Art Unit 2823

703-306-0098

julio.maldonado@uspto.gov

Olik Chaudhuri **Supervisory Patent Examiner** 

chath

Page 6

**Technology Center 2800**